



N-Channel Enhancement MOSFET

Features

- Drain-Source Breakdown Voltage V_{DSS} 30V
- Drain-Source On-Resistance
 $R_{DS(ON)}$ 11mΩ, at $V_{GS} = 10V$, $I_D = 15A$
 $R_{DS(ON)}$ 16mΩ, at $V_{GS} = 4.5V$, $I_D = 15A$
- Continuous Drain Current at $T_C = 25^\circ C$ $I_D = 39A$
- Advanced high cell density Trench Technology
- RoHS Compliance & Halogen Free

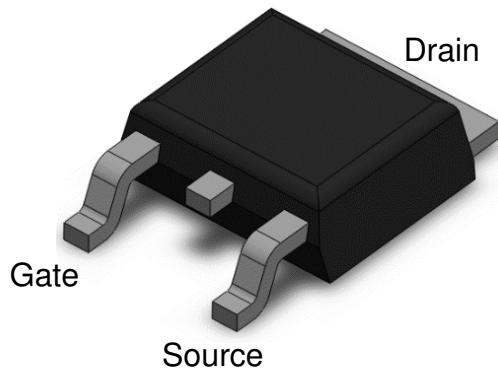
Description

The CTH3903NS-T52 is the N-Channel logic enhancement mode power field effect transistors are produced using high cell density, DMOS trench technology. This high density process is especially tailored to minimize on-state resistance. These devices are particularly suited for low voltage application.

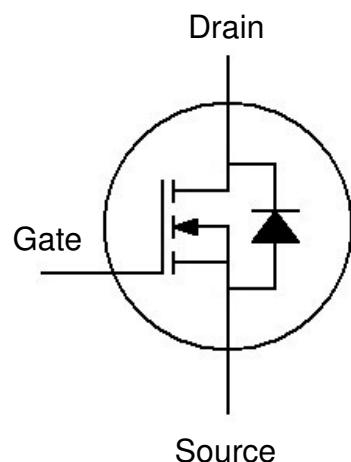
Applications

- DC/DC Converter
- Power Management
- Battery Powered System

Package Outline



Schematic





CTH3903NS-T52

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Absolute Maximum Rating at 25°C

Symbol	Parameters	Test Conditions	Min	Note
V _{DS}	Drain-Source Voltage	30	V	
V _{GS}	Gate-Source Voltage	±20	V	
I _D	Continuous Drain Current @T _c =25°C	39	A	1
I _{DM}	Pulsed Drain Current	100	A	1
P _D	Total Power Dissipation @T _c =25°C	37	W	2
T _{STG}	Storage Temperature Range	-55 to 150	°C	
T _J	Operating Junction Temperature Range	-55 to 150	°C	

Thermal Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
R _{θJC}	Thermal Resistance Junction-Case		--	--	3.3	°C /W	1,4



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Electrical Characteristics $T_A = 25^\circ\text{C}$ (unless otherwise specified)

Static Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
V_{BDSS}	Drain-Source Breakdown Voltage	$V_{GS} = 0V, I_D = 250\mu\text{A}$	30	-	-	V	
$I_{DS}S$	Drain-Source Leakage Current	$V_{DS} = 30V, V_{GS} = 0V$	-	-	1	μA	
$I_{GS}S$	Gate-Source Leakage Current	$V_{GS} = \pm 20V, V_{DS} = 0V$	-	-	± 100	nA	

On Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
$R_{DS(ON)}$	Drain-Source On-Resistance	$V_{GS} = 10V, I_D = 15A$	-	11	15	$\text{m}\Omega$	3
		$V_{GS} = 4.5V, I_D = 15A$		16	20	$\text{m}\Omega$	
$V_{GS(th)}$	Gate-Source Threshold Voltage	$V_{GS} = V_{DS}, I_D = 250\mu\text{A}$	1.0	2	3.0	V	3

Dynamic Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
C_{iss}	Input Capacitance	$V_{GS} = 0V,$ $V_{DS} = 15V$ $f = 1\text{MHz}$	-	700	800	pF	
C_{oss}	Output Capacitance		-	120	-		
C_{rss}	Reverse Transfer Capacitance		-	35	-		

Switching Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
$T_{D(ON)}$	Turn-On Delay Time	$V_{DS} = 15V,$ $V_{GS} = 10V,$ $R_G = 3\Omega, R_L = 1.5\Omega,$ $I_D = 10A$	-	14	17	ns	
T_R	Rise Time		-	12	15		
$T_{D(OFF)}$	Turn-Off Delay Time		-	43	55		
T_F	Fall Time		-	4	6		
Q_G	Total Gate Charge	$V_{DS} = 15V,$ $V_{GS} = 10V,$ $I_D = 10A$	-	20	26	nC	
Q_{GS}	Gate-Source Charge		-	5	-		
Q_{GD}	Gate-Drain (Miller) Charge		-	4.9	-		



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Drain-Source Diode Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
V _{SD}	Body Diode Forward Voltage	V _{GS} = 0V, I _{SD} = 1A	-	0.75	1.1	V	1
I _{SD}	Body Diode Continuous Current		-	-	1.0	A	1

Note:

1. The power dissipation is limited by 150°C junction temperature.
2. The data tested by pulsed , pulse width \leq 300μs , duty cycle \leq 2%
3. Thermal Resistance follow JESD51-3.



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Typical Characteristic Curves

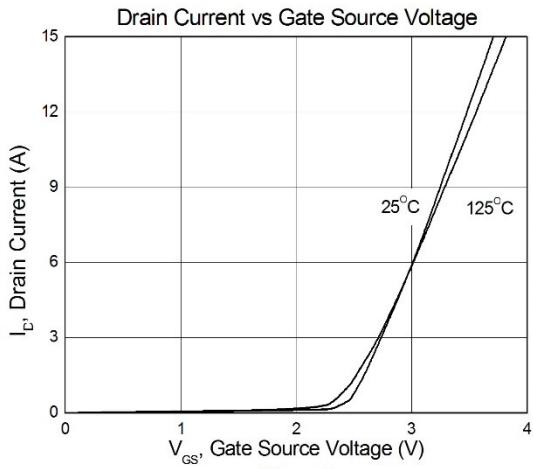


Figure 1

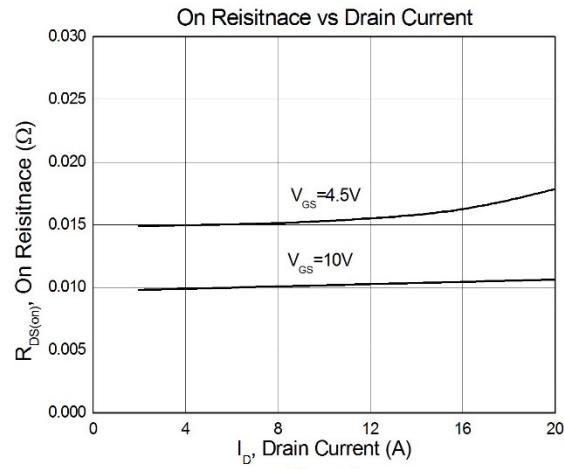


Figure 2

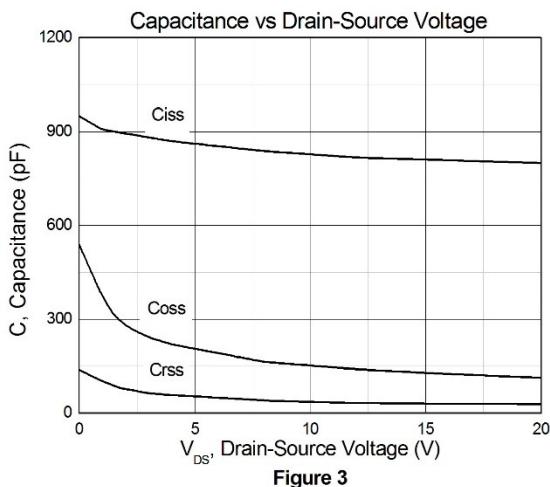


Figure 3

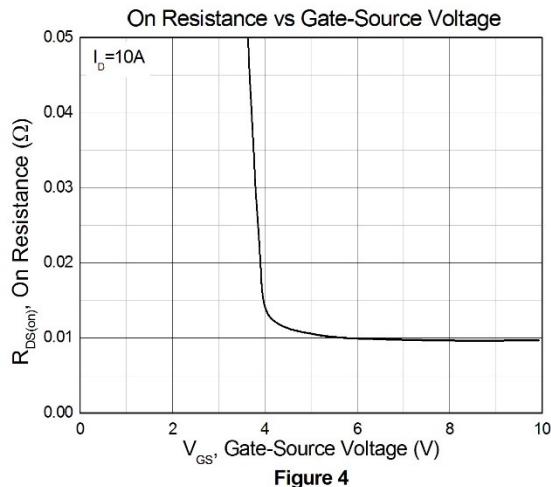


Figure 4

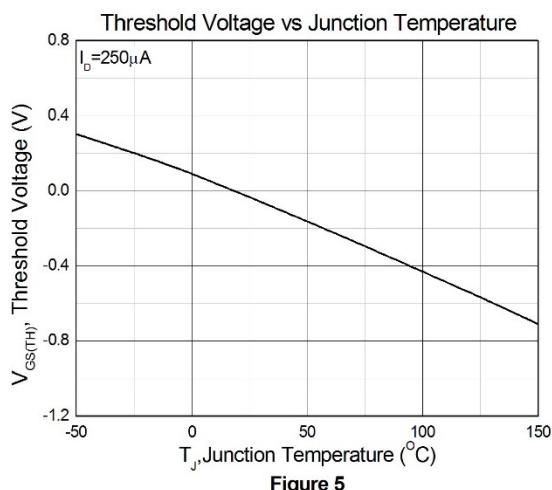


Figure 5

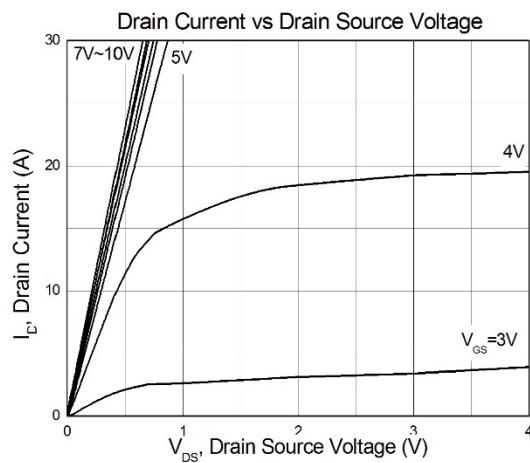


Figure 6



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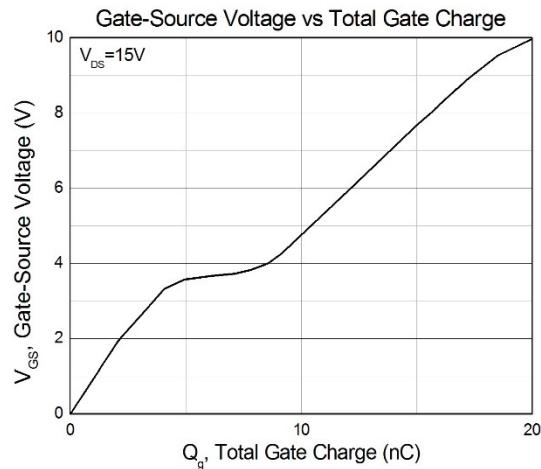


Figure 7

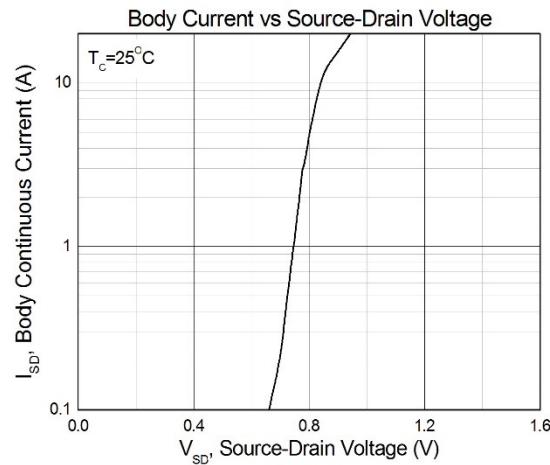


Figure 8



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Test Circuits & Waveforms

Figure 9: Gate Charge Test Circuit

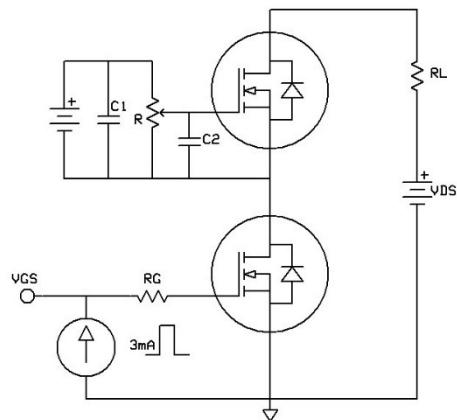


Figure 10: Gate Charge Waveform

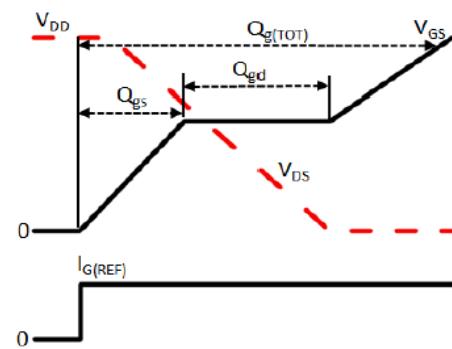


Figure 11: Switching Time Test Circuit

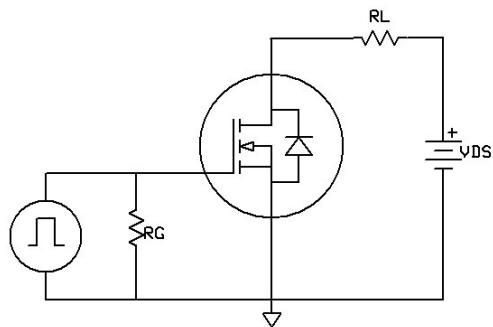
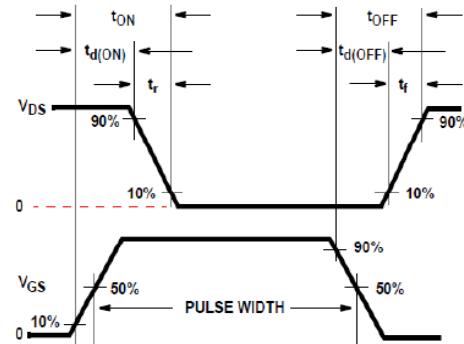


Figure 12: Switching Time Waveform

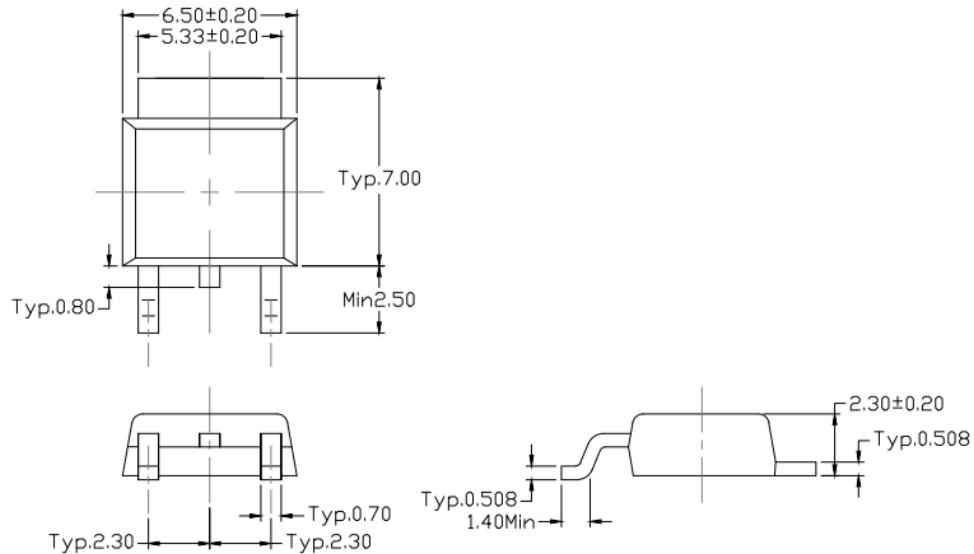




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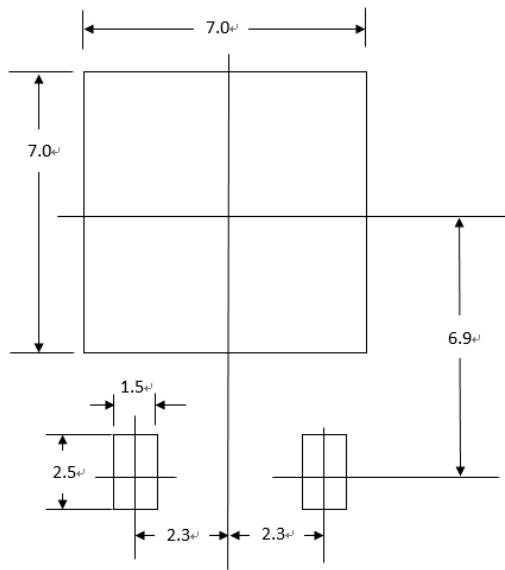
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Package Dimension (TO-252)



Dimensions in mm unless otherwise stated

Recommended pad layout for surface mount leadform

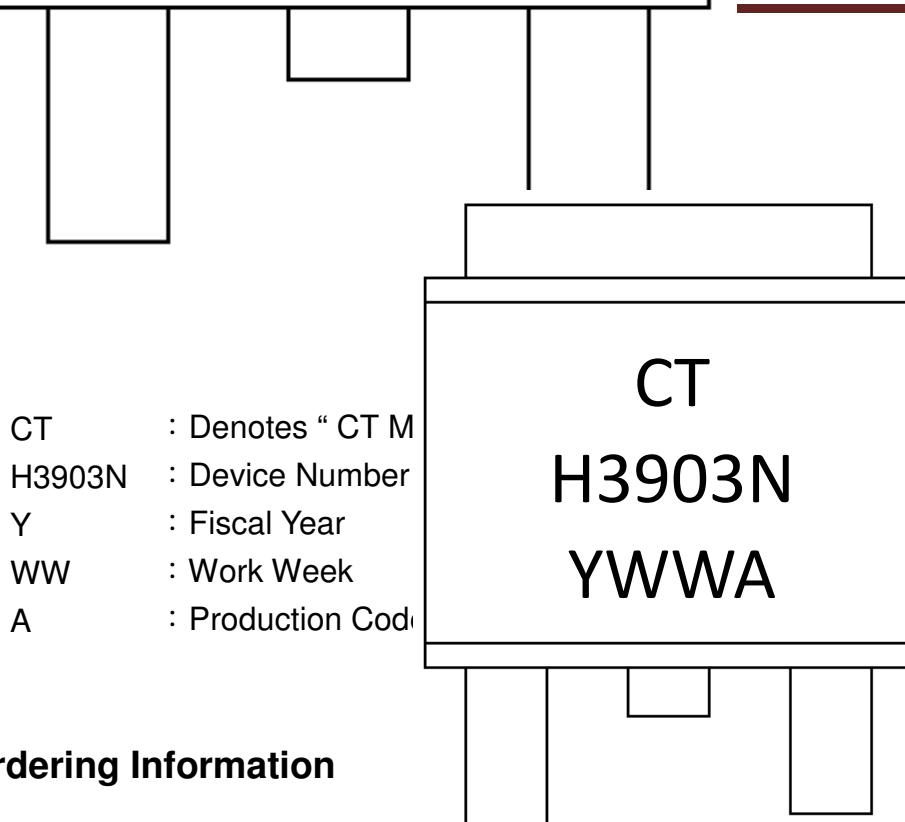


Dimensions in mm unless otherwise stated

CTH3903N
YWWA

CTH3903NS-T52

Channel Enhancement MOSFET



CT : Denotes "CT M"
H3903N : Device Number
Y : Fiscal Year
WW : Work Week
A : Production Code

Ordering Information

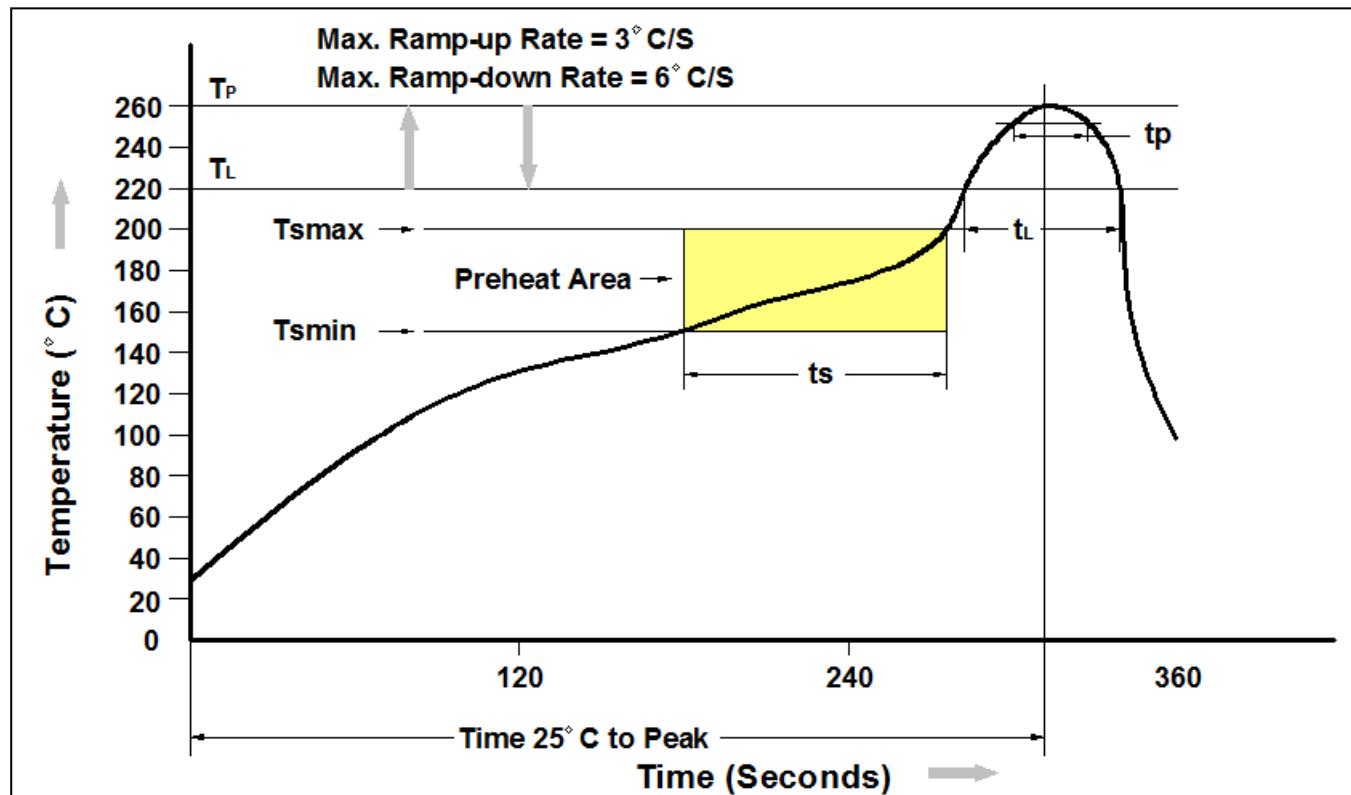
Part Number	Description	Quantity
CTH3903NS-T52	TO-252 Reel	2500 pcs



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Reflow Profile



Profile Feature	Pb-Free Assembly Profile
Temperature Min. (Tsmin)	150°C
Temperature Max. (Tsmax)	200°C
Time (ts) from (Tsmin to Tsmax)	60-120 seconds
Ramp-up Rate (tL to tp)	3°C/second max.
Liquidous Temperature (TL)	217°C
Time (tL) Maintained Above (TL)	60 – 150 seconds
Peak Body Package Temperature	260°C +0°C / -5°C
Time (tp) within 5°C of 260°C	30 seconds
Ramp-down Rate (Tp to TL)	6°C/second max
Time 25°C to Peak Temperature	8 minutes max.



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